



<b>Experiment title:</b> The structure of InSb Quantum Dots		<b>Experiment number:</b> 28-01-63
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<b>Shifts:</b>	<b>Local contact(s):</b> Dr. Anne Stunault	<i>Received at XMaS:</i>

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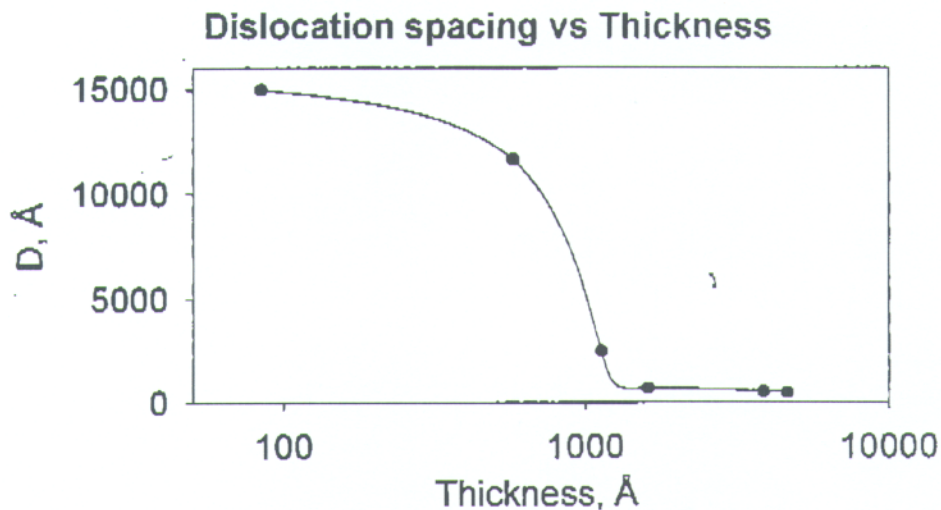
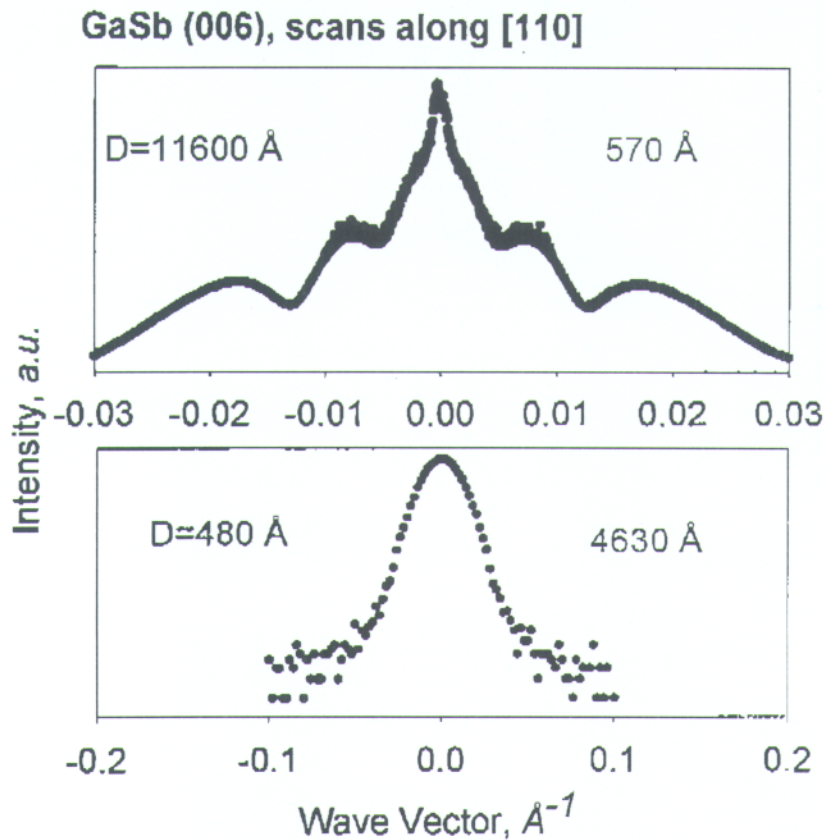
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**Report:**

The experimental efforts were concentrated on a second part of the original proposal due to some technical problems with a MOCVD facility and unavailability of new samples of InSb. Some preliminary measurements were made on Si/Ge wavy superlattices instead of InSb for which we had samples. These showed an indication of scattering from quantum dots which we would like to investigate more carefully in a separate project.

We have measured x-ray scattering from GaSb epilayers grown on InAs substrate with the thickness from 80 Å to 4630 Å. We have studied the x-ray scattering for wave-vector transfers near the (002), (004), (006) and (115) reflections. Scans were performed by varying the wave-vector transfer along the [110] and [001] directions. Thickness of the film, lattice constants of GaSb and InAs and uniform strain were reduced from the measurements.

We have found two stages of lattice relaxation: one with low dislocation density and the other with high density of dislocations. A quick transition between the two regimes is taking place between 1100 Å and 1600 Å and we called it a critical thickness  $T_{C2}$  to distinguish it from the critical thickness at which very first misfit dislocations are formed. Below 570 Å the GaSb films are almost lattice matched but scans parallel to the [110] direction already show clear evidence of diffuse scattering typical for systems containing low density of  $60^\circ$  dislocations, see a figure. Scans parallel to [001] direction through the satellites shown in the figure reveal a coherence length similar to the film thickness. This means that the  $60^\circ$  dislocations cross the whole film and therefore they probably originate from the threading dislocations. An average separation distance between the dislocations  $D$  was calculated from



a carefully measured in-plane lattice mismatch  $f_{\parallel}$  as  $D = b_{\text{eff}}/f_{\parallel}$ , where  $b_{\text{eff}}$  is an effective Burger's vector. Variation of  $D$  with a film thickness is shown in the figure. A peak aspect ratio ( $\Delta q_{[001]}/\Delta q_{[110]}$ ) for thick (3855  $\text{\AA}$  and 4630  $\text{\AA}$ ) samples was found to be about 0.34. According to a theory by Kaganer et al. [Phys. Rev. B 55 (1997) 1793] this indicates that in a high dislocation density regime ( $T > T_{c2}$ ) the dislocations are of  $60^\circ$  type and the  $D$  values calculated from the theory using the measured aspect ratio are comparable to those found from the in-plane lattice mismatch.

A uniform strain shows a sharp increase when the thickness changes from 570  $\text{\AA}$  to 1600  $\text{\AA}$  and indicates the first stages of a rapid relaxation taking place between 1100  $\text{\AA}$  and 1600  $\text{\AA}$ .